

To:	File			
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Subject:	Measured Parallelism and Concentricity of Band 6 Cartridge SN001			

# Summary

The parallelism of the 4K stage with respect to the 300K baseplate is about 26  $\mu$ m. This means that the 4K plate is tilted 0.15 milliradian or only 3% of the 5 milliradian beam centering specification.

The worst-case concentricity of the 100K, 20K, and 4K plates with respect to the 300K baseplate is about 300  $\mu$ m, which is less than RAL's measured value of 456  $\mu$ m.

Consequently, flipping and rotating the G10 sections doesn't degrade the parallelism or the concentricity of the first Band 6 cartridge.

## Introduction

Parallelism of the 4K plate relative to the 300K baseplate and concentricity of all cold stages relative to the 300K baseplate are important mechanical requirements for the Band 6 cartridge:

- 1. to maintain stringent 5 milliradian beam pointing accuracy specifications, because the optical components are mounted on the 4K stage, and
- 2. to prevent damage to Dewar cold finger assemblies when inserting and removing the cartridge from either the cartridge test Dewar or the receiver.

The G10 spacer sections for all stages in the Band 6 cartridge were flipped and rotated to the align access holes with interior components located between each stage. Those changes could alter the:

- 1. planarity of the 4-K stage with respect to the 300K baseplate (which we define as parallelism), and the
- 2. concentricity of all cold stages with respect to the 300K baseplate.

This memo documents the mechanical measurements obtained after cartridge construction to confirm no significant changes occurred in either parallelism or concentricity.

## **RAL Mechanical Measurements**

Figure 1 is mechanical data measured by RAL for their first Band 6 cartridge. Detailed descriptions of the procedures used to measure these data were requested but not yet received.

### **Measurement Locations**

Figure 2 shows the locations on the 4K stage for the NRAO's planarity measurements. The planarity was measured relative to the 300K baseplate, and the measurement locations on the 300K baseplate were directly below the 4K locations but outside the G10 spacer.

### 1.1 Planarity

Planarity was obtained by measuring the height of the four sets of test locations shown in Figure 2 using a Starrett 708B dial gauge held to a granite table with a Starrett 254 Master Height Vernier. Heights relative to location "B" were measured on the 4K plate. The planarity measurement was repeated on the 300K plate at locations almost directly below the 4K locations, but just outside the G10 spacer. We define parallelism as the planarity of the 4-K stage with respect to the vacuum side of the 300K baseplate, which means that the 4K planarity

Measurements					
Heights (ir					
Diata	Location				
Fiale	А	В	С	D	
300K	-0.00035	0	0	-0.0004	
4K	0.0007	0	-0.0002	-0.0005	
Difference between 4K and 300K plates (parallelism):					
inches	0.00105	0	-0.0002	-0.0001	
mm	0.026	0	-0.005	-0.002	

Table 1: Planarity and Parallelism

data was normalized by the corresponding measurements on the 300K baseplate and is shown in the last line in Table 1. The worst-case parallelism is 26  $\mu$ m compared with RAL's measured worse-case value of 17  $\mu$ m as shown in Figure 1.

### 1.2 Concentricity

Concentricity was measured with an Ono Sokki EG225 digital dial gauge mounted on a rugged stand made in China but constructed similar to the Starrett 254 and clamped to the granite table. The dial indicator measured the distance along a longitudinal cut from the outer wall of the 300K baseplate to the outer walls of the 110K, 20K and 4K plates. The bottom edge of the outer wall of the baseplate was selected as a reference because RAL measured a circularity of only 9  $\mu$ m and a concentricity of only 3  $\mu$ m for that wall. To account for differences in plate diameters as a function of the longitudinal distance on the cartridge, the outer walls were measured near their bottom and top (just below the bevel) edges and both sets of data were recorded.

Figure 3 serves as a consistency check by showing the difference in diameter of the top edge of the 300K baseplate with respect to the bottom. Figure 3 also shows the repeatability of the reference position obtained after measuring the top and bottom edges of the 100K, 20K, and 4K plates.

The measured concentricity results are shown in Figure 4 along with the results for an ideal cartridge. The taper starting with the 100K stage and continuing through the 4K stage is evident in the measured data. If concentricity is defined as the maximum discrepancy in distance between the ideal and measured positions, then the maximum concentricity is about 300  $\mu$ m in the direction of "A". This is less than the 456  $\mu$ m measured by RAL and shown in Figure 1.

# Conclusions

The parallelism of the 4K stage with respect to the 300K baseplate is about 26  $\mu$ m. This means that the 4K plate is tilted 26  $\mu$ m over the 170 mm diameter of the 4K plate, so the tilt angle is

$$\theta_{Tilt} = \tan^{-1} \left( \frac{0.026}{170} \right) = 0.15 \ mrad$$

or only 3% of the 5 mrad beam centering specification.

The worst-case concentricity of the 100K, 20K, and 4K plates with respect to the 300K baseplate is about 300  $\mu$ m, which is less than RAL's measured value of 456  $\mu$ m.

Consequently, flipping and rotating the G10 sections doesn't degrade the parallelism or the concentricity of the first Band 6 cartridge.



Figure 1: RAL Measured Mechanical Data for Band 6 Cartridge SN001 File \\Cvfiler\cv-cdl-sis\Cartridge\Documentation\Cartridge01\Mechanical\RAL001.pdf









Figure 4: Concentricity Data